

Docket No.

AMENI	DMENT	RANSM	LITALL	ELIER		M4065.0210/P210
Applicatio	n No.	Filing Date		Examiner		Art Unit
09/588,008		June 6, 2000		Hoa B. Trinh		2814
olicant(s): Yan		Y CELL CAPA	CITOR STRU	JCTURE A	ND METH	OD OF FORMATIO
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	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rat	te	IOD OF FORMATIO
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Independent Claims	3	- 3 =	0	x		0.00
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Thomas J. DAr Attorney Reg. N				Da	ted: <u>S</u> e	eptember 4, 2002
DICKSTEIN SH	IAPIRO MORII	N & OSHINSK	Y LLP			

Washington, DC 20037-1526 (202) 828-2232



Docket No.: M4065.0210/P210 (PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Yang et al.

Application No.: 09/588,008

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Filed: June 6, 2000

For: IMPROVED MEMORY CELL CAPACITOR

STRUCTURE AND METHOD OF

**FORMATION** 

Group Art Unit: 2814

#10 | And | Building

Examiner: Vikki H. Trinh

AMENDMENT UNDER 37 CFR §1.116

ATTN: BOX AF

Commissioner for Patents Washington, DC 20231

Dear Sir:

This paper is in response to the Office Action dated June 4, 2002 finally rejecting claims 1-31, 97, and 98, please amend the above-captioned U.S. Patent application as follows:

In the Claims:

Please replace claims 1, 97, and 98 with amended claims 1, 97, and 98 below.

1. (amended) A capacitor for a semiltonductor device, said capacitor comprising:

a bottom conducting layer;

a dielectric layer formed over said bottom conducting layer; and

an annealed oxygen permeable top conducting layer formed over said dielectric

1499532 v1; W51\_01!.DOC